

Exposure dose vs 250nm line width and Exposure dose vs 250 nm pillars diameter.
 Developing step done on Developer-TMAH-tepper.

Dose, J/m ²	Linewidth, nm	Pillars diameter, nm
110	not resolved	not resolved
120	not resolved	366
130	not resolved	
140	353	304
150	300	287
160	310	221
170	307	223
180	300	227
190	286	221
200	265	187
210	252	173
220	250	149
230		156
240		



